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Thermal and Spectroscopic Analyses of Next Generation Caustic Side Solvent Extraction Solvent (CSSX) Contacted with 3, 8, and 16 Molar Nitric Acid

F. F. Fondeur
S. D. Fink

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Savannah River National Laboratory
Savannah River Nuclear Solutions, LLC
Aiken, SC 29808

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REVIEWS AND APPROVALS

AUTHORS:

F.F. Fondeur, Separations and Actinide Science Programs

Date

TECHNICAL REVIEW:

D. T. Hobbs, Separations and Actinide Science Programs

Date

APPROVAL:

S.D. Fink, Manager and Co-author
Separations and Actinide Science Programs

Date

S.L. Marra, Manager
Environmental & Chemical Process Technology Research Programs

Date

B.A. Oard, Manager
MCU Life Extension/NGS

Date

J. E. Occhipinti,
SRR Engineering

Date

EXECUTIVE SUMMARY

A new solvent system referred to as Next Generation Solvent or NGS, has been developed at Oak Ridge National Laboratory for the removal of cesium from alkaline solutions in the Caustic Side Solvent Extraction process. NGS is proposed for deployment at MCU and at the Salt Waste Processing Facility. This work investigated the chemical compatibility between NGS and 16 M, 8 M, and 3 M nitric acid from contact that may occur in handling of analytical samples from MCU or, for 3 M acid, which may occur during contactor cleaning operations at MCU.

This work shows that reactions occurred between NGS components and the high molarity nitric acid. In the case of 16 M and 8 M nitric acid, initially organo-nitrate groups are generated and attach to the modifier and that with time oxidation reactions convert the modifier into a tarry substance with gases (NO_x and possibly CO) evolving. Calorimetric analysis of the organo-nitrate revealed the reaction products are not explosive nor will they deflagrate.

NGS exposure to 3 M nitric acid resulted in much slower reaction kinetics and that the generated products were not energetic.

We recommended conducting Accelerated Rate calorimetry on the materials generated in the 16 M and 8 M nitric acid test. Also, we recommend continue monitoring of the samples contacting NGS with 3 M nitric acid.

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LIST OF ABBREVIATIONS

Cs-7SB (or modifier)	1-(2,2,3,3-tetrafluoropropoxy)-3-(4- <i>sec</i> -butylphenoxy)-2-propanol
CSSX	Caustic-Side Solvent Extraction
DCiTDG	<i>N,N'</i> -dicyclohexyl- <i>N''</i> -isotridecylguanidine, marketed by Cognis as Lix®79
D _{Cs}	distribution ratio for cesium
DF	decontamination factor
DSC	differential scanning calorimetry
FTIR	Fourier transform infrared spectroscopy
HPLC	High Performance Liquid Chromatography
MaxCalix	1,3- <i>alt</i> -25,27-Bis(3,7-dimethyloctyloxy) calix[4]arene-benzocrown-6
MCU	Modular Caustic-Side Solvent Extraction Unit
NGS	Next Generation Solvent
ORNL	Oak Ridge National Laboratory
SRNL	Savannah River National Laboratory
SRS	Savannah River Site
SVOA	Semi-volatile Organic Analysis

1.0 Introduction

A solvent extraction system for removal of cesium from alkaline solutions was developed utilizing a novel solvent invented at the Oak Ridge National Laboratory (ORNL).¹ This solvent consists of a calix[4]arene-crown-6 extractant dissolved in an inert hydrocarbon matrix. A modifier is added to the solvent to enhance the extraction power of the calixarene and to prevent the formation of a third phase. An additional additive is used to improve stripping performance and to mitigate the effects of any surfactants present in the feed stream. The process that deploys this solvent system is known as Caustic Side Solvent Extraction (CSSX). The solvent system has been deployed at the Savannah River Site (SRS) in the Modular CSSX Unit (MCU) since 2008.

The MCU uses centrifugal contactors (10-in for extraction stages and 5-in for scrub and strip stages) to provide mechanical mixing and phase separation between the solvent and alkaline waste solutions by way of two separations. The first separation extracts cesium from the waste solutions into the solvent system; the second separation strips the cesium from the solvent system while providing a nominal cesium concentration factor of 15. From its radioactive start-up in April 2008 until the end of August 2011, MCU processed approximately 2 million gallons of HLW solution for disposition. The decontaminated salt solution is sent to the SRS Saltstone Production Facility and the concentrated cesium stream is transferred to Defense Waste Processing Facility.

Subsequent development efforts by ORNL have identified an improved solvent system that can raise the expected decontamination factor (DF) in MCU from ~200 to more than 40,000.² The improved DF is attributed to an increased distribution ratio for cesium (D_{Cs}) in extraction from ~15 to ~60, an increased solubility of the calixarene in the solvent from 0.007 M to 0.050 M, and use of boric acid (H_3BO_3) stripping that yields D_{Cs} values less than 0.01. The improved solvent system contains four components: 1) 0.050 M 1,3-*alt*-25,27-Bis(3,7-dimethyloctyloxy) calix[4]arene-benzocrown-6, also known as MaxCalix, is the extractant; 2) 0.50 M 1-(2,2,3,3-tetrafluoropropoxy)-3-(4-*sec*-butylphenoxy)-2-propanol, or Cs-7SB, is the modifier; 3) 0.003 M *N,N'*-dicyclohexyl-*N''*-isotridecylguanidine, or DCiTDG, is the suppressor; and 4) C_{12} -isoparaffinic hydrocarbon, or Isopar[®] L, is the diluent. The modified solvent system is referred to as the Next Generation Solvent (NGS).

During MCU and Salt Waste Processing Facility operations, unexpected shut downs and planned shut downs for maintenance will occur. Periodically during operations, salts will deposit in the contactors requiring cleaning the units. The flushing operation for cleaning the centrifugal contactors will use 3 M nitric acid. Contacting with more concentrated acids (e.g., 3 M) may also prove beneficial for deposits that dissolve slowly in the 1 M acid. Also, processing samples from MCU in F/H Labs involves the potential risk of inadvertent disposal of residual solvent to the drain system or contact with concentrated (16M) nitric acid. For the baseline solvent, prior studies assessed the reaction rates of the solvent with various concentrations of nitric acid.^{3,4,5} Savannah River National Laboratory (SRNL) conducted similar tests with the new solvent contacting 3, 8, and 16 M to provide analogous safety bases data.^{6,7,8}

2.0 Experimental Procedure

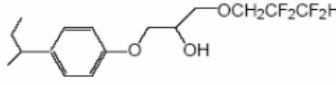
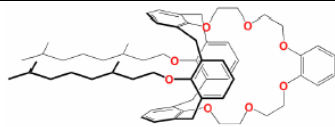
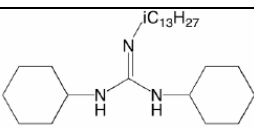
Personnel took 20 mL of NGS (whose composition is shown in Table 1) and 40 mL of either 16 M, 8 M, or 3 M nitric acid and placed the two liquids in a 60 mL bottle (Teflon[™] capped containing a 2 mm hole for gas release). The bilayer configuration (no mixing) represents likely scenarios during sampling disposal to waste drains or stagnant cleaning periods in the contactors.

Two samples per each nitric acid concentration were prepared: one sample was used for visual tracking with time (photographs) and the other sample was used to provide samples of “physically” distinguishable layers for chemical analysis (by Fourier transform infrared spectroscopy, FTIR) and energetic screening by Differential Scanning Calorimetry (DSC). Some samples were submitted for Semi-volatile Organic Analysis (SVOA) and High Performance Liquid Chromatography (HPLC) analysis (from the NGS layer). The amount of sample removed from each testing bottle was approximately 0.5 mL (to ensure enough liquid remained for future testing). The small liquid samples (removed for analysis) were placed in 2 mL glass bottles (sized to avoid a large overhead that may change the composition of the removed liquid). Testing begun at 08:10 on 14 September 2011 and this time is considered “time zero” for this test.

FTIR of the samples was conducted with a Nicolet Nexus 670 instrument using a single bounce attenuated reflectance diamond crystal. More than 100 scans were collected at a resolution of 4 cm^{-1} to obtain signal to noise ratios greater than 340.

DSC was conducted with Perkin Elmer PE7 instrument. Approximately 7.4 mg of sample was placed in gold crucible that was covered with a gold lid (loosely placed over the cup) and then heated at 20°C per min. The lid was in placed on gold cup to minimize liquid splashing out of the cup, however, the lid was not sealed, which allowed gas release.

Table 1. Component composition of Next Generation Solvent

Component	Next Generation Solvent concentration
Modifier	 21 wt %
Isopar [®] L	Linear/branched C-12 alkanes 74 wt %
MaxCalix	 50 mM
DCiTDG Cognis)	(from  3 mM

3.0 Results and Discussion

Personnel analyzed the optical pictures using ImageJ^{*} software to obtain both histogram and line profile to determine the width of the different layers in the bottles (as shown in Figure 3.1). The

^{*} ImageJ is the public domain software “Image Processing and Analysis in JAVA” available via the National Institute of Health.

histogram was used to determine the color intensity in a given layer. When two or more colors were present in a layer the histogram will show numerous (some overlapping with each other). The mode of each peak was registered and used to determine the color of that layer. A typical image analysis is shown in Fig. 3.1 where a multimode histogram was de-convoluted into single peaks belonging to the different layers in a sample (in this case NGS in 16 M nitric acid). The peak mode for both the organic (top layer) and aqueous layer (bottom layer) and sometimes the interfacial layer was recorded as a function of time.

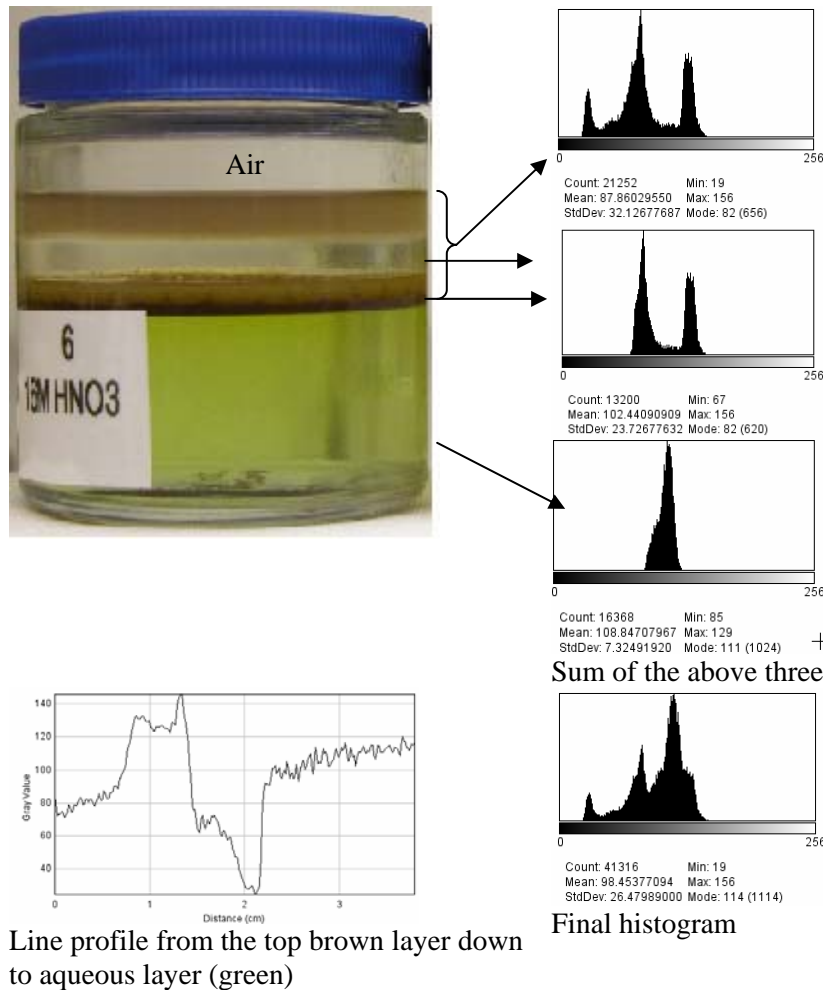


Figure 3.1. A typical breakdown of the histogram into the layers visible in a digital image. The mode of each peak was used to determine the color intensity with time. Also included is a line profile for estimating thickness of each layer.

Personnel also analyzed the different layers by FTIR. To train the reader to read the FTIR data, Figure 3.2 shows the FTIR spectrum of each of the four components in NGS. As can be seen from Fig. 3.2 each NGS component has a unique absorption peak that can be used for identification. In the case of nitration, nitro-alkanes have a unique peak in the 1601-1531 cm^{-1} region (1381-1310 cm^{-1} for the asymmetric stretching) while the nitro-aromatics have a unique peak at 1587-1555 cm^{-1} (1357-1318 for the asymmetric stretching).⁹ Exothermic reactions in the DSC were evaluated against reported enthalpy of explosives in Fig. 3.3.

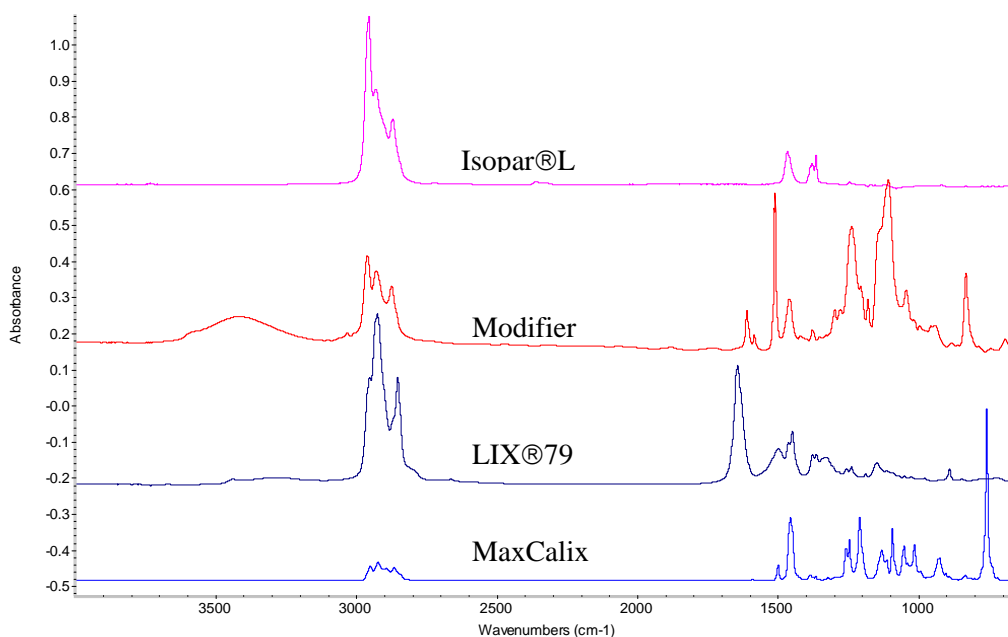


Fig. 3.2 The FTIR spectrum of the NGS components for identification in the subsequent figures.

Thermal stability of nitrocompounds

Compounds	T_{onset} (°C)	$-\Delta H$ (Jg ⁻¹)	$-\Delta H$ (kJ mol NO ₂ ⁻¹)
Ammonium nitrate	250	1577	126
Nitrobenzene	380	2757	339
Nitromethane	320	5292	323
2-Nitrophenol	250	2481	345
3-Nitrophenol	310	2269	316
4-Nitrophenol	270	2155	300
2-Nitrotoluene	290	2404	329
3-Nitrotoluene	310	2070	284
4-Nitrotoluene	320	2322	318
2-Nitroaniline	280	2225	307
3-Nitroaniline	300	2269	314
4-Nitroaniline	310	2026	279
2-Nitrobenzoic acid	270	1894	297
3-Nitrobenzoic acid	300	1899	298
4-Nitrobenzoic acid	310	1934	304
1,2-Dinitrobenzene	280	3310	259
1,3-Dinitrobenzene	270	3488	293
1,4-Dinitrobenzene	350	3701	311
2,4-Dinitrotoluene	250	3574	298
3,4-Dinitrotoluene	280	3987	333
2,6-Dinitrotoluene	290	3451	288
1-Chloro-4-nitrobenzene	395	2283	360
2,4-Dinitrophenol	240	3598	331
2,4,6-Trinitrophenol	220	5130	391

T_{onset} : onset temperature; ΔH : enthalpy change.

Fig. 3.3 The enthalpy of decomposition of energetic (explosive) materials (from Y. S. Duh, C. Lee, C. C. Hsu, D. R. Hwang, and C. S. Kao, "Chemical Incompatibility of Nitrocompounds," Journal of Hazardous Materials, 53 (1997), 183-194).

NGS in 16 M Nitric Acid

We observed that components of the NGS immediately react with 16M nitric acid as evidenced by the development of highly colored regions at the organic/aqueous interface and the aqueous phase. Fig. 3.4 shows a series of pictures taken after 2, 4.5 and 6 hours of contact. A plot of the mode for both the aqueous and organic layer as a function of time is shown in Fig. 3.5. As can be seen in Fig. 3.5, the pixel value for the aqueous layer decreased rapidly initially, remains constant for about 2 hours and then begins to decrease again. This behavior suggests at least two different diffusions into (or out of) the aqueous layer. However, the data at 14:12 hours is suspect since NO_x gas was generated that influenced the color in the aqueous. In contrast, the histogram mode for the organic layer exhibits a small increase during the first 90 minutes followed by a rapid decrease over the next five hours. Indicating a possible single phenomenon occurred (again the data at 14:12 is suspect due to NO_x). For example, a steady diffusion and reaction of components in or out of the organic layer may give a steady color change. Also note that the color from the aqueous did not add into the color of the organic as one may expect from a multiple scattering sample (for example the light from the aqueous layer travels in every direction and some of that light hits the organic layer thereby adding to the color of the organic layer but the magnitude of that effect is not significant in this situation).

Results from spectroscopic and calorimetric analysis of samples taken from the upper organic phase, the highly colored interfacial region, and the lower aqueous phase are shown in Fig. 3.6 (after 4.5 hours of exposure). The upper organic layer is mostly Isopar[®] L with a small amount of nitrated modifier (1528 cm^{-1}). The modifier, guanidine derivative, and MaxCalix reacted immediately with 16 M nitric acid leaving behind Isopar[®] L. This is the expected trend since the hydrocarbon diluent, Isopar[®] L would be the least reactive organic component in the solvent system. On the other hand, solvent components with aromatic groups and hydroxyls (alcohols) are more susceptible to nitration and oxidation. Both the modifier and the MaxCalix contain aromatic groups. Also, the guanidine suppressor contains an amine group with pKa value of 10 that readily ionizes and partitions to the aqueous phase.¹⁰ The organic compounds formed upon reaction of the extractant, modifier and suppressor with nitric acid are much more polar and dense and would be expected to diffuse into the aqueous solution resulting in a separation from Isopar[®] L. The remaining organic layer gave an exothermic peak of -10.17 J/g indicating residual nitrated modifier in that layer.

The lower aqueous layer had a high concentration of organic (mostly reacted modifier). The organics in the aqueous layer did not decompose energetically as noted by the absence of an exothermic peak in the DSC plot and the absence of an organo-nitro peak (at 1530 cm^{-1}) in the FTIR spectra. However, the peak at 1620 and 1280 cm^{-1} could be due to a trinitroxy propane like molecule but since no energetic was detected in the DSC test, this molecule has no impact on this system (an ARC test of this layer may provide further evidence of the lack of energy seen by the DSC). Please note that the large endothermic peak in the DSC figure is due to water boiling from the aqueous layer and that boiling process did not steam-strip the organic from the sample since the baseline in the DSC curve was nearly restored to the values before the evaporation (for a large evaporation or mass loss, the baseline is always higher in value after the event).

The interface between the organic and aqueous layer was intensely colored and consisted mostly of nitrated organic as evidenced by the presence of strong bands around 1560 , 1526 and 1341 cm^{-1} which are indicative of organo-nitro groups. The DSC analysis indicated a large and broad exothermic peak with an exothermic energy of -605 J/g . This energy is well below the lower

bound energy of 1000 J/g (see Figure 3.3). The exothermic decomposition is broad enough that the reaction does not meet the definition of a deflagration reaction.¹¹

NGS in 8 M Nitric Acid

A series of pictures and sample removal was performed on the sample containing NGS and 8 M nitric acid. A characteristic set of pictures is shown in Fig. 3.7. A similar image analysis exercise was conducted on these images. The mode associated with the aqueous and organic layer was recorded (from the multimode histogram). As can be seen in Fig. 3.8, the organic layer proceeded steadily from its initial yellow color to the red color (an S-shaped curve resembling that of diffusion was observed) while the aqueous layer remained nearly transparent during this time; there was a “yellow” colored front moving into the aqueous layer. Since measuring the diffusion front (by Fick’s diffusion) is not an objective in this task, this front speed is not reported here although the data exist. This visual behavior is an indication that the type of reactions and their kinetics are different from those observed in the 16 M nitric acid tests.

A spectroscopic and calorimetric analysis of the sample (NGS in 8 M nitric acid) is shown in Fig. 3.9. As can be seen from Fig. 3.9, the organic layer is mostly the unreacted modifier containing a smaller concentration of Isopar®L and an even smaller concentration of reacted modifier that contains little organo-nitro groups (as indicated by the small peak at 1560 cm⁻¹ in the FTIR spectrum) after 120 hours of contact with 8M nitric acid. The corresponding calorimetric scan indicates a very weak and broad exotherm near 167 °C with an enthalpy value of -7.1 J/g. In this case it is possible that the nitric acid migrated into the organic layer and reacted with the modifier and the heat from that reaction may have evaporated Isopar® L.

Similarly, the aqueous layer contains a small amount of organic that upon heating in the DSC generated a very small and broad exotherm near 160 °C right after water boiled from the sample. Again, indicating the absence of energetic material in this layer.

Samples from the interface were collected but the analysis from those samples are not available for this report, but will be reported in a future report.

NGS in 3 M Nitric Acid

Figures 3.10 and 3.11 show the color evolution (due to reaction), spectroscopic identification and calorimetric behavior of NGS and 3 M nitric acid. The data from the histogram analysis was not available for this report but from Fig. 3.10, the organic layer from the 16 September 2011 picture show less color intensity (and more transparency) than the color seen in the 14 September and 26 September 2011 pictures. This may indicate a possible change in lighting condition when the 14 September 2011 picture was taken. The histogram analysis of the picture will be reported in a later report. The spectroscopic and calorimetric analysis (Fig. 3.11) of this sample after 48 hours of exposure indicates that neither the organic layer nor the aqueous layer has changed significantly. This indicates a much slower reaction and that longer time is required to detect changes with these instruments. In fact, Fig. 3.12 shows NGS in 16 M, 8 M and 3 M nitric acid 288 hours after the test and from this picture it can be seen that the NGS layer in the 3 M nitric acid sample, a yellow colored front is moving through the NGS layer. Also note that the interface between NGS and the 8 M nitric acid sample has darkened and thickened (possibly indicating a new byproduct from a reaction). Liquid from these samples were removed and will be analyzed and reported later.

4.0 Conclusions

A new solvent system referred to as Next Generation Solvent or NGS, has been developed at Oak Ridge National Laboratory for the removal of cesium from alkaline solutions in the Caustic Side Solvent Extraction process. This work investigated the chemical compatibility between NGS and 16 M, 8 M, and 3 M nitric acid typically used throughout the operations and analysis of MCU solvent.

NGS components readily react with 16M and 8M nitric acid solutions. In the case of 16 M and 8 M nitric acid, initially organo-nitrate groups are generated and attach to the modifier and that with time oxidation reactions turns the organic into a tarry substance with gases (NO_x and possibly CO) evolved. Calorimetric analysis of the organo-nitrate revealed these materials are not explosive nor will they deflagrate.

NGS exposure to 3 M nitric acid resulted in much slower reaction kinetics and that the generated products were not energetic.

We recommend conducting Accelerated Rate calorimetry on the materials generated in the 8 M nitric acid test.

5.0 Recommendations, Path Forward or Future Work

We recommend conducting Accelerate Rate calorimetry of the material generated in the 8 M nitric acid test. Also to analyze the aqueous layer from the 16M and 8M test for IC Anions (fluorides). We also recommend continued testing of the 3 M acid sample.

6.0 References

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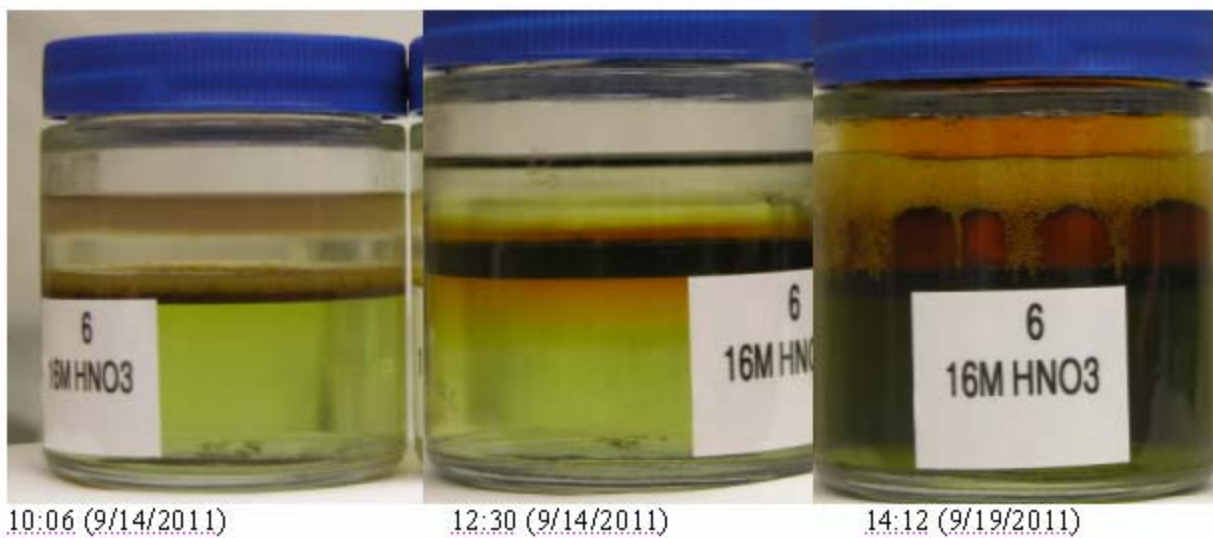


Fig. 3.4. A typical evolution in the chemical reaction between NGS and 16 M nitric acid.

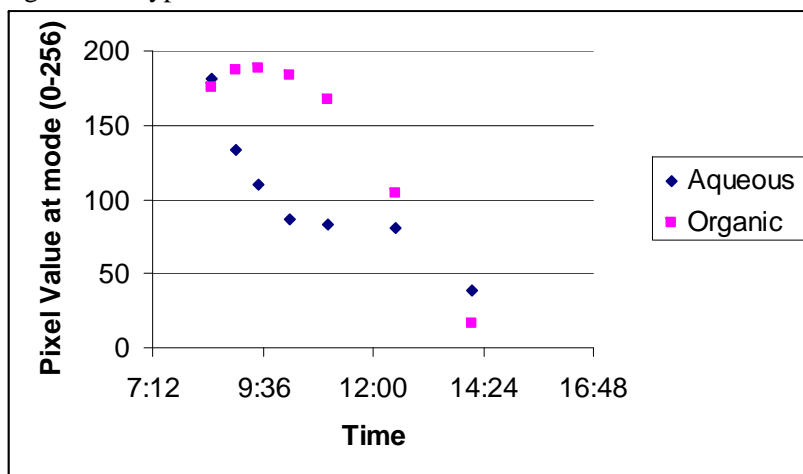


Fig. 3.5 A plot of the histogram mode for both aqueous (16 M nitric acid) and organic layer (NGS) as a function of time

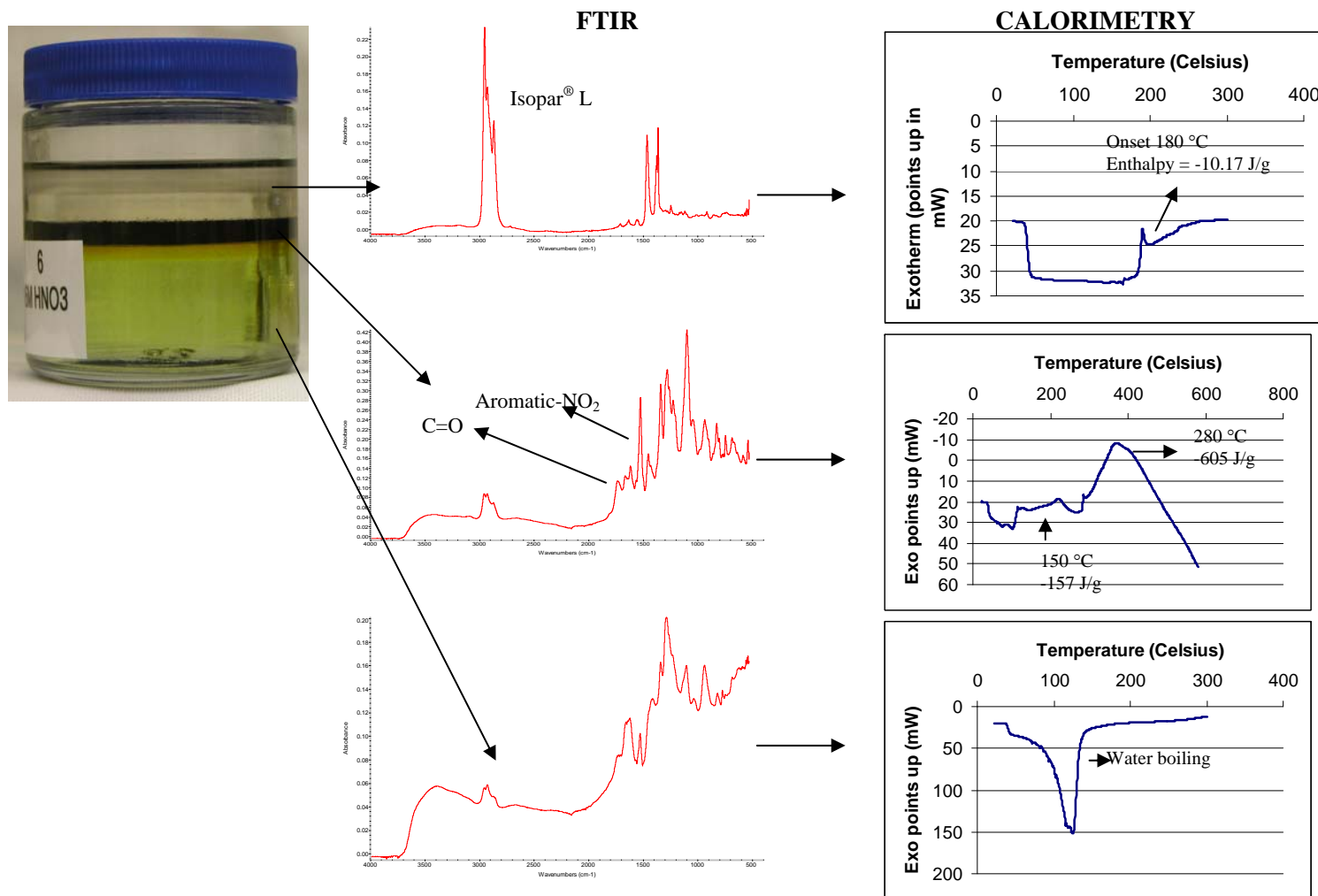
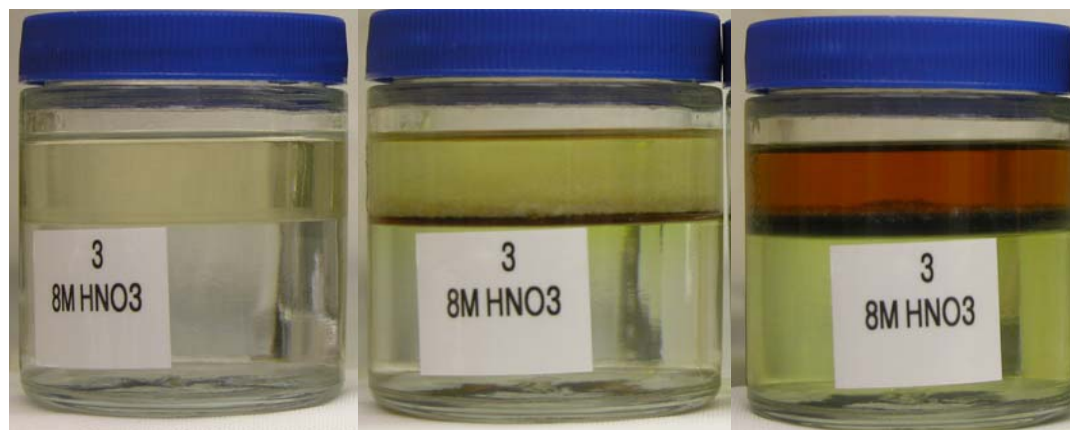


Figure 3.6. The energetic and chemistry of NGS after 4.5 hours in 16 M nitric acid



09:56 (9/14/2011)

11:53 (9/16/2011)

14:14 (9/19/2011)

Fig.3.7 Temporal evolution of NGS in 8 M nitric acid

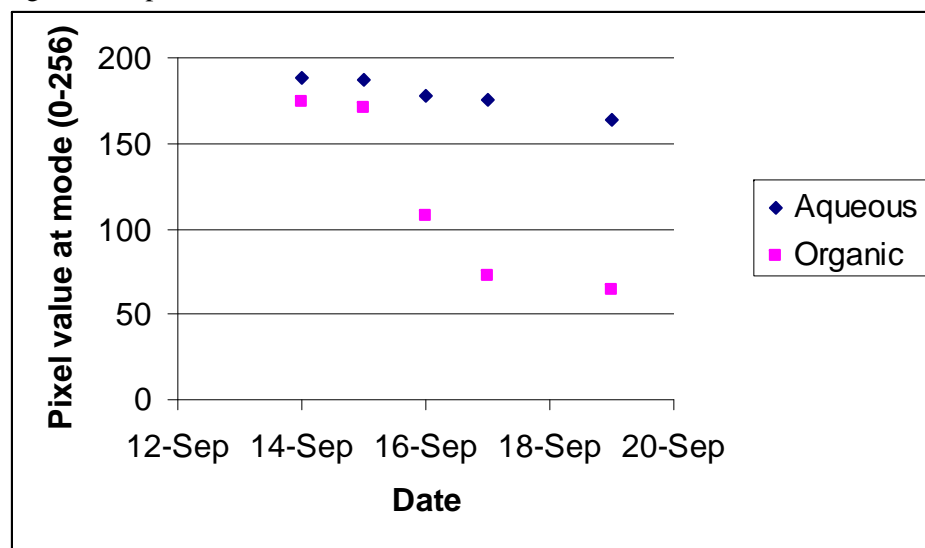


Fig. 3.8 The temporal evolution of the histogram mode for both aqueous (8 M nitric acid) and NGS

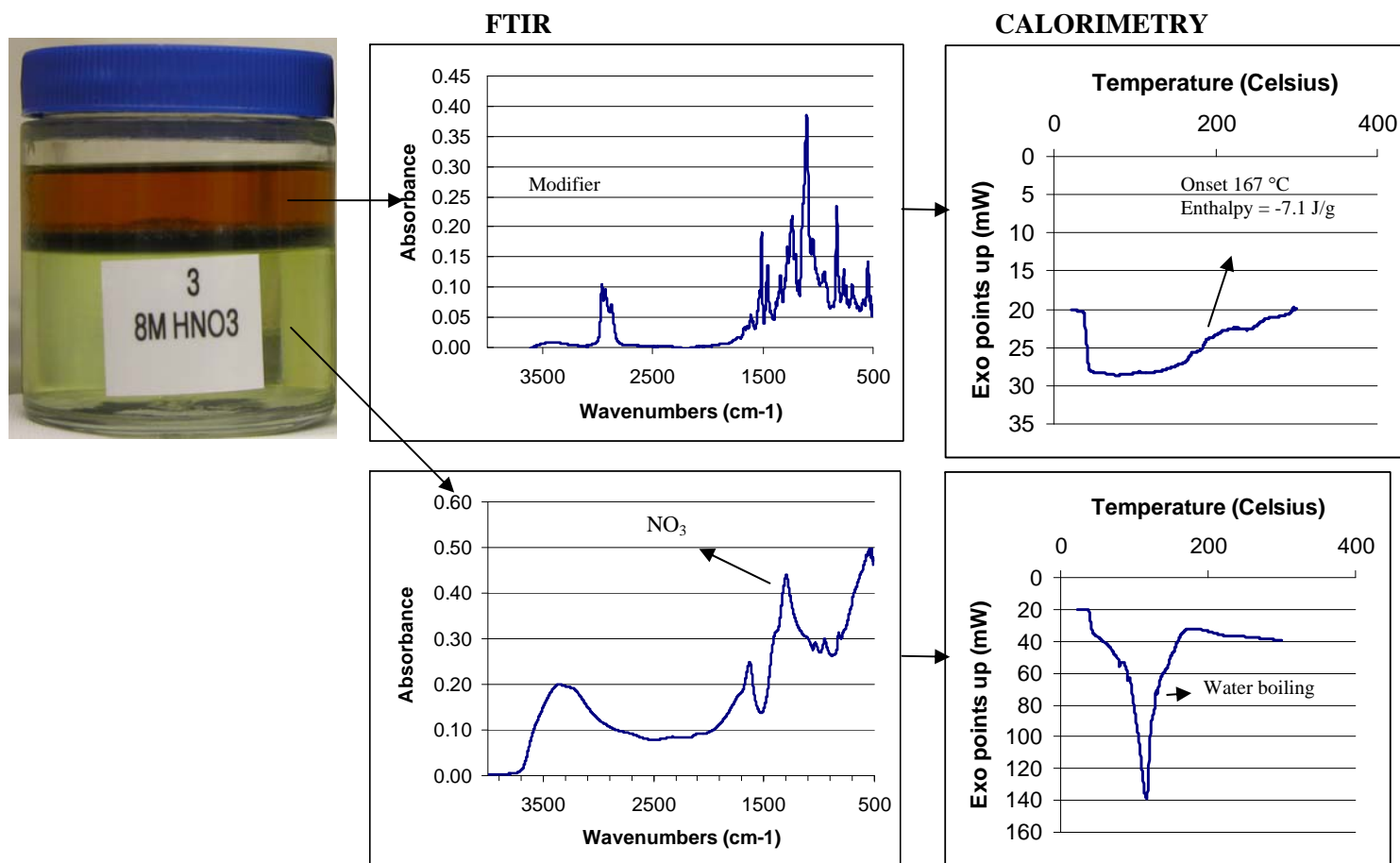


Figure 3.9. The energetic and chemistry of NGS after 120 hours in 8 M nitric acid

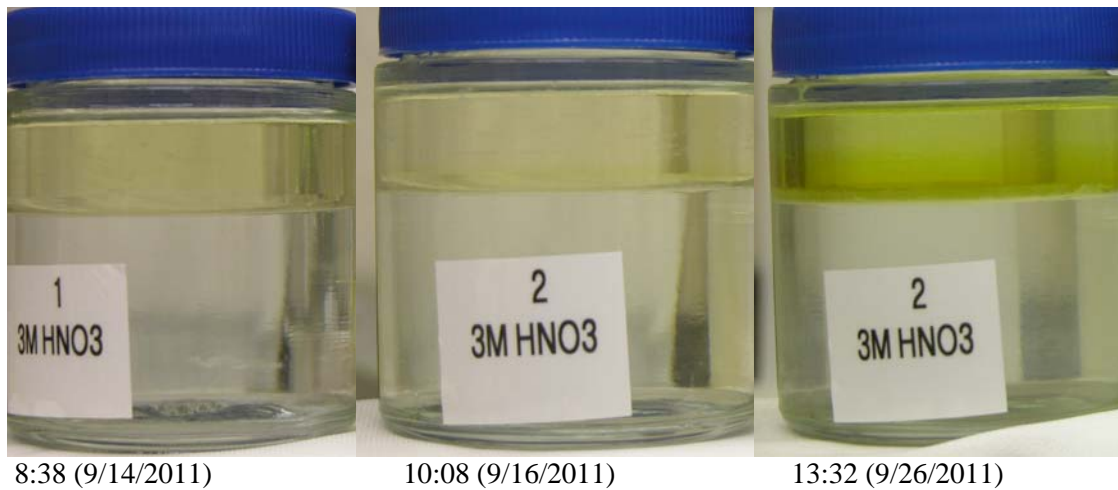


Fig. 3.10 The temporal evolution of NGS in 3 M nitric acid.

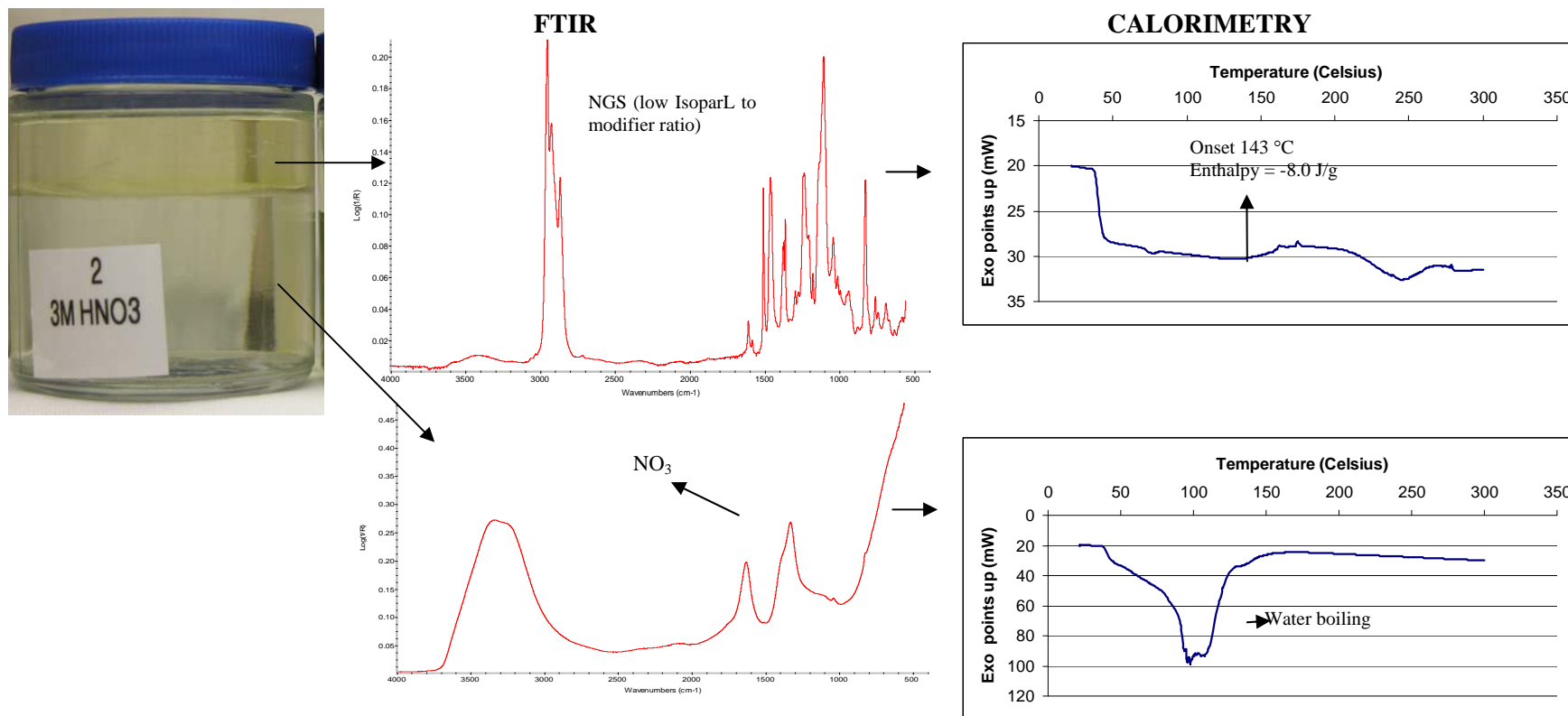


Figure 3.11. The energetic and chemistry of NGS after 48 hours in 3 M nitric acid

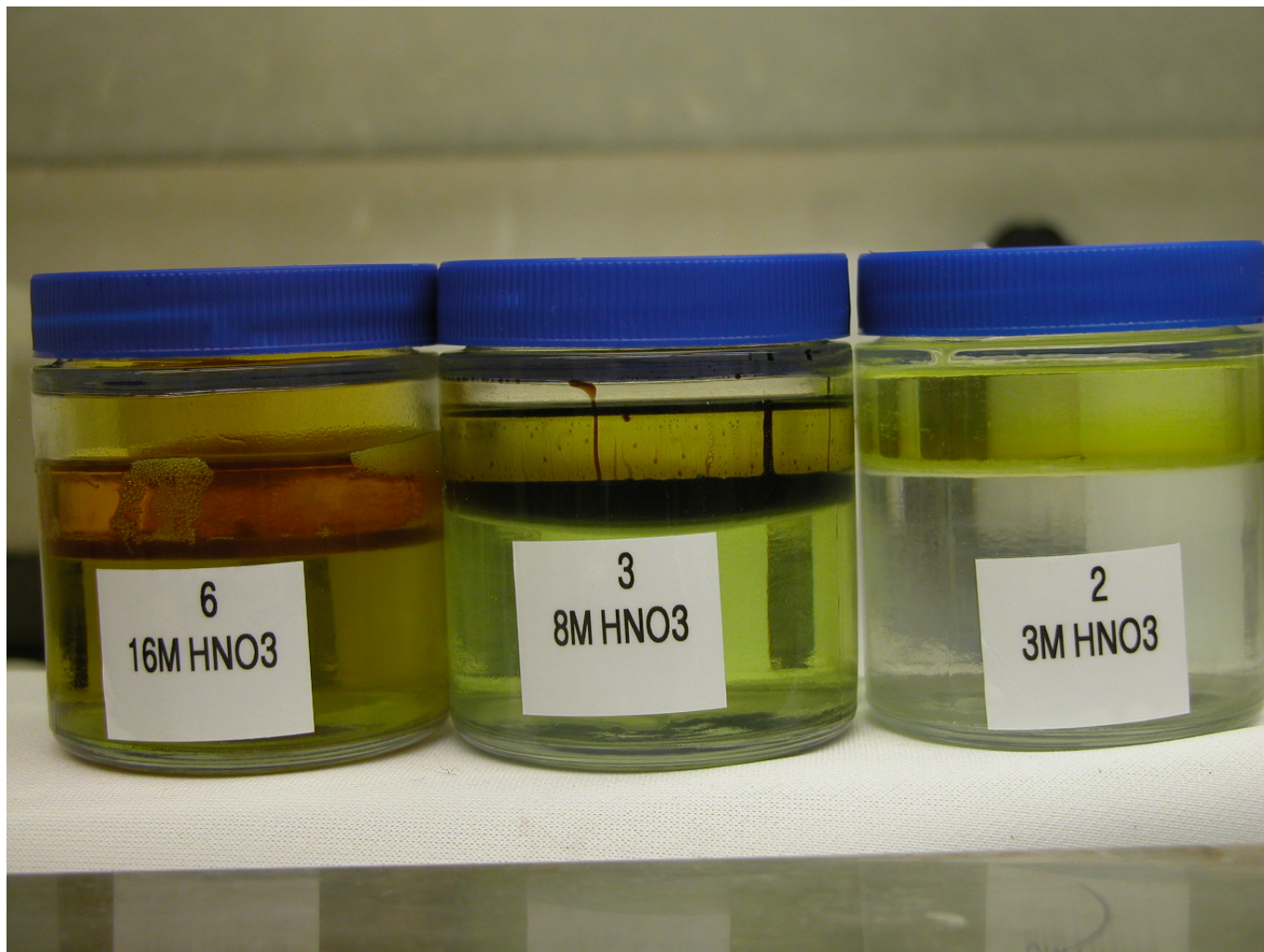


Fig. 3.12. The physical appearance of NGS after 288 hours in 16 M, 8 M and 3 M nitric (note the lower liquid level at higher nitric acid concentration).

Distribution:

A. B. Barnes, 999-W
S. D. Fink, 773-A
B. J. Giddings, 786-5A
C. C. Herman, 999-W
S. L. Marra, 773-A
F. M. Pennebaker, 773-42A
W. R. Wilmarth, 773-A
J. C. Griffin, 773-A
T. B. Peters, 773-42A
R. A. Pierce, 773-A
F. F. Fondeur, 773-A

R. T. McNew, 704-27S
J. E. Occhipinti, 704-S
J. W. Ray, 704-S
H. B. Shah, 766-H
D. C. Sherburne, 704-S
R. E. Edwards, 773-67A
M. W. Geeting, 241-152H
B. A. Gifford, 704-56H
B. A. Oard, 241-197H
A. Samadi, 241-197H
S. McLeskey, 241-152H
D. J. Martin, 241-152H
E. J. Freed, 704-56H

W. Brasel, 992-2W
C. Conner, Parsons
R. D. Lentsch, Parsons
M. S. Brugh, Parsons
T. D. Burns, Parsons
A. N. Singer, Parsons
M. J. Thomas, Parsons
R. J. Schepens, Parsons
R. K. Leugemors, 992-5W
P. G. Suggs, 704-S
B. A. Moyer, ORNL
L. Delmau, ORNL
J. Birdwell, ORNL
R. A. Leonard, ANL
P. Jackson, 703-46A